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(11) **EP 0 771 645 A1**

(12) **EUROPEAN PATENT APPLICATION**

(43) Date of publication:
07.05.1997 Bulletin 1997/19

(51) Int. Cl.⁶: **B41C 1/10, G03F 7/016**

(21) Application number: 95202936.1

(22) Date of filing: 31.10.1995

(84) Designated Contracting States:
BE DE FR GB NL

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(54) **On-press development of a lithographic printing plate having an aryldiazosulfonate resin in a photosensitive layer**

(57) The present invention discloses a method for making a lithographic printing plate comprising the steps of:

- (1) image-wise exposing an imaging element having on a hydrophilic surface of a lithographic base a photosensitive layer comprising a photosensitive polymer containing aryl-diazosulfonate units;
- (2) and developing a thus obtained image-wise exposed imaging element by mounting it on a print cylinder of a printing press and supplying an aqueous dampening liquid and/or ink to said photosensitive layer while rotating said print cylinder.

Excellent printing results are obtained with a printing plate prepared according to the above described method. The lithographic base may be an anodized aluminium or a support provided with an ink-repellant layer containing a cross-linked hydrophilic binder.

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Description

1. Field of the invention

The present invention relates to a method for making a printing plate involving the use of a aryldiazosulfonate resin based printing plate. In particular, the method of the present invention involves on press development of an aryldiazosulfonate resin based printing plate.

2. Background of the invention

Lithography is the process of printing from specially prepared surfaces, some areas of which are capable of accepting lithographic ink, whereas other areas, when moistened with water, will not accept the ink. The areas which accept ink form the printing image areas and the ink-rejecting areas form the background areas.

In the art of photolithography, a photographic material is made imagewise receptive to oily or greasy inks in the photo-exposed (negative-working) or in the non-exposed areas (positive-working) on a hydrophilic background.

In the production of common lithographic printing plates, also called surface litho plates or planographic printing plates, a support that has affinity to water or obtains such affinity by chemical treatment is coated with a thin layer of a photosensitive composition. Coatings for that purpose include light-sensitive polymer layers containing diazo compounds, dichromate-sensitized hydrophilic colloids and a large variety of synthetic photopolymers. Particularly diazo-sensitized systems are widely used.

Several types of supports can be used for the manufacturing of a diazo-sensitized lithographic printing plate. Common supports are metal supports like Al or Zn and paper bases. These supports, if not sufficient hydrophilic by themselves, are first coated with a hydrophilic layer to form the hydrophilic background of the printing plate and a top layer containing the diazo compound is then applied (see for example DE-P-1900469, DE-P-2030634 and US-P-3971660).

It is known to use as hydrophilic layer in these systems a layer containing polyvinyl alcohol and hydrolyzed tetraethyl orthosilicate and preferably also silicium dioxide and/or titanium dioxide as described in e.g. EP-A 601240, GB-P-1419512, FR-P-2300354, US-P-3971660 and 4284705. This hydrophilic layer is overcoated with a light-sensitive layer containing a diazo resin or a diazonium salt in a polymeric binder.

Upon image-wise exposure of the light-sensitive layer the exposed image areas become water insoluble and the unexposed areas remain water soluble. The plate is then developed with water to remove the diazonium salt or diazo resin in the unexposed areas.

Commercially available diazo based printing plates most commonly use an anodized and roughened aluminium as a support having a hydrophilic surface. Printing plates of this type offer the advantage of high printing endurance, resolution and sharpness. However, they require special developing liquids and dedicated processors to process the printing plates. Such procedure is time consuming, inconvenient and puts a burden on the environment.

On the other hand commercial plates are also available that use a flexible support such as paper provided with a hydrophilic layer. For example, Lithocraft 10008 FOTOPLATE™ is a diazo based printing plate that comprises on a paper support a hydrophilic layer on top of which is provided a diazo based photosensitive layer. According to plate instructions of the supplier, a plate can be prepared by image-wise exposure of the lithographic printing plate precursor or imaging element, mounting the exposed imaging element on the press and wiping its surface with Lithocraft® 10008 Developer Desensitizer. The plate instructions also contemplate a method wherein no developer desensitizer is used. However, such method most often results in poor lithographic performance so that in practice a Developer Desensitizer is almost always needed.

EP-A 339393 and EP-A 507008 disclose the use of aryldiazosulfonate resins in a photosensitive layer of an imaging element for making a lithographic printing plate. According to these disclosures, the imaging elements can be developed by rinsing them with plain water.

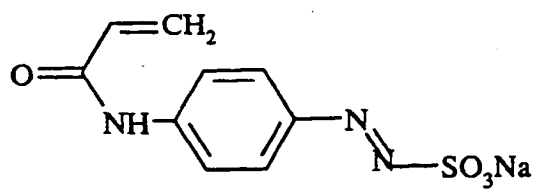
3. Summary of the invention

It is an object of the present invention to provide a convenient and environmental friendly way of obtaining printing plates that yield excellent printing properties such as printing endurance, ink-acceptance of the image areas and ink-repellance of the non image areas.

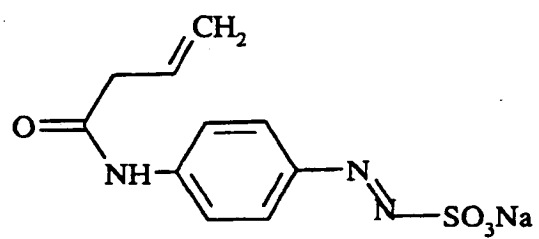
Further objects of the present invention will become clear from the description hereinafter.

According to the present invention there is provided a method for making a lithographic printing plate comprising the steps of:

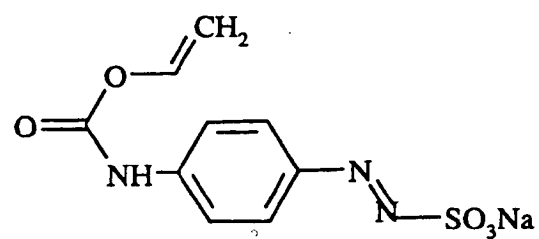
- (1) image-wise exposing an imaging element having on a hydrophilic surface of a lithographic base a photosensitive layer comprising a photosensitive polymer containing aryl-diazosulfonate units;
- (2) and developing a thus obtained image-wise exposed imaging element by mounting it on a print cylinder of a



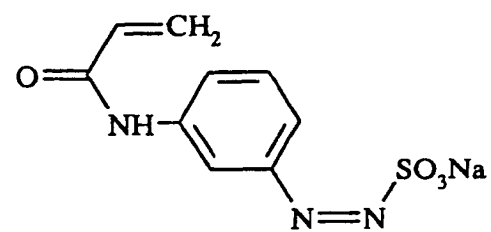
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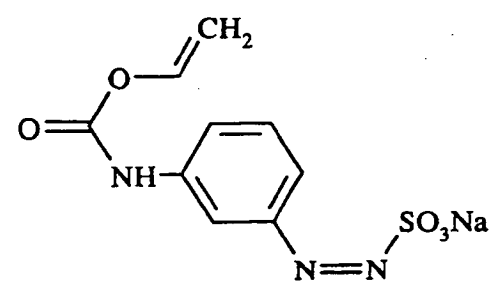
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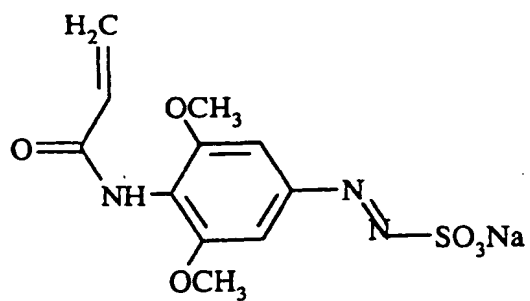
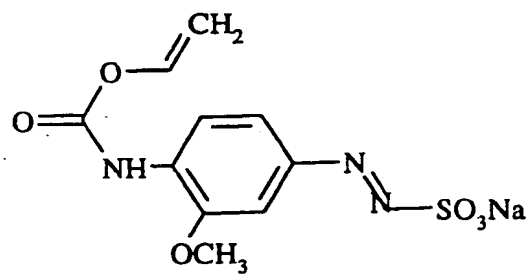
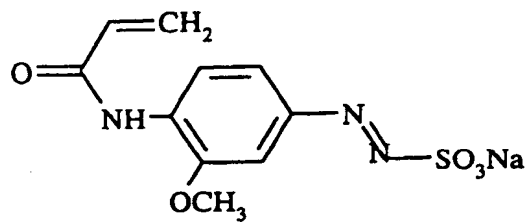
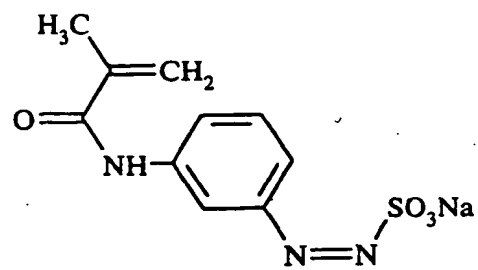
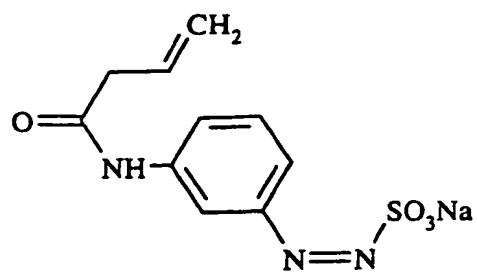
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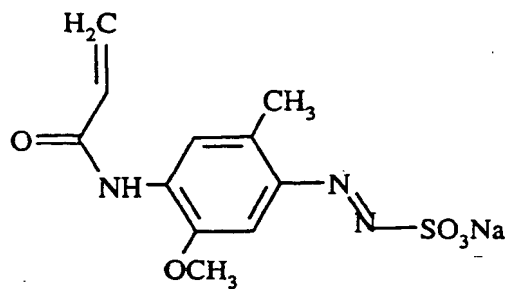
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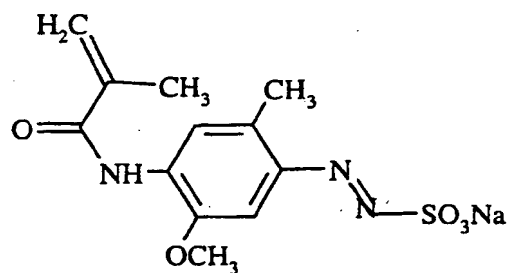
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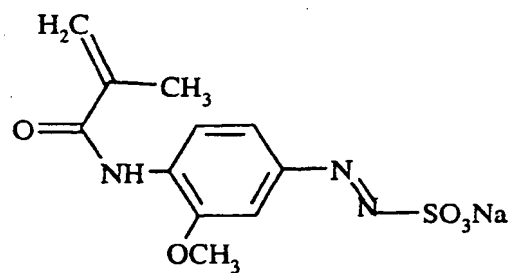
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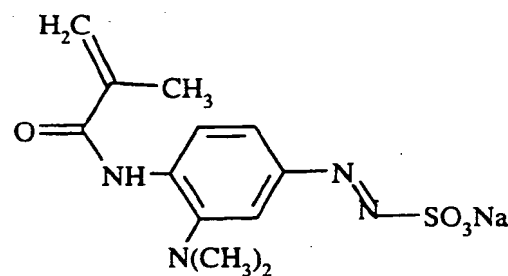
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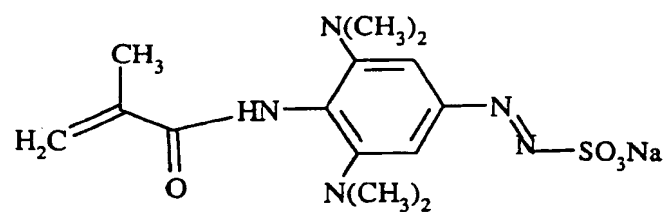
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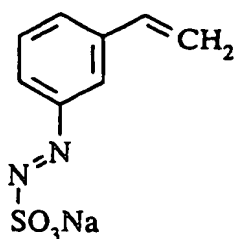
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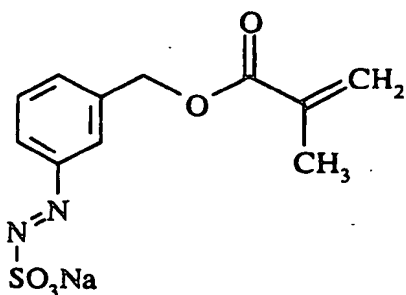
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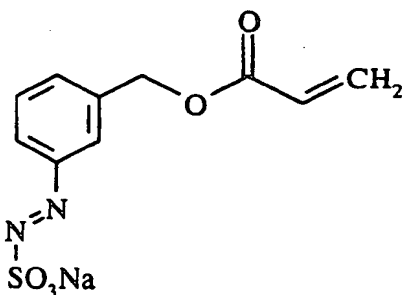
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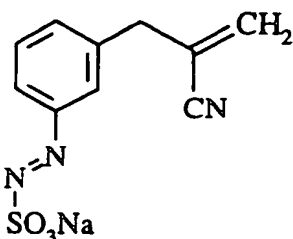
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M18



M19

Aryldiazosulfonate monomers, e.g. as disclosed above, can be homopolymerised or copolymerised with other aryl-diazosulfonate monomers and/or with vinyl monomers such as (meth)acrylic acid or esters thereof, (meth)acrylamide, acrylonitrile, vinylacetate, vinylchloride, vinylidene chloride, styrene, alpha-methyl styrene etc.. In case of copolymers however, care should be taken not to impair the water solubility of the polymer. Preferably, the amount of aryl-diazosul-
fonate groups in a polymer in connection with this invention is between 10mol% and 60mol%.

According to another embodiment in connection with the present invention, an aryl-diazosulfonate containing poly-
mer may be prepared by reacting a polymer having e.g. acid groups or acid halide groups with an amino or hydroxy sub-
stituted aryl-diazosulfonate. Further details on this procedure can be found in EP-A 507008.

According to a preferred embodiment in connection with the present invention, the lithographic base can be an ano-
dised aluminium. A particularly preferred lithographic base is an electrochemically grained and anodised aluminium
support. According to the present invention, an anodised aluminium support may be treated to improve the hydrophilic
properties of its surface. For example, the aluminium support may be silicated by treating its surface with sodium silicate
solution at elevated temperature, e.g. 95°C. Alternatively, a phosphate treatment may be applied which involves treating
the aluminium oxide surface with a phosphate solution that may further contain an inorganic fluoride. Further, the alu-

minium oxide surface may be rinsed with a citric acid or citrate solution. This treatment may be carried out at room temperature or can be carried out at a slightly elevated temperature of about 30 to 50°C. A further interesting treatment involves rinsing the aluminium oxide surface with a bicarbonate solution. It is further evident that one or more of these post treatments may be carried out alone or in combination.

According to another embodiment in connection with the present invention, the lithographic base comprises a flexible support, such as e.g. paper or plastic film, provided with an ink-repellant layer comprising a cross-linked hydrophilic binder. A particularly suitable ink-repellant layer may be obtained from a hydrophilic binder cross-linked with a cross-linking agent such as formaldehyde, glyoxal, polyisocyanate or a hydrolysed tetraalkylorthosilicate. The latter is particularly preferred.

As hydrophilic binder there may be used hydrophilic (co)polymers such as for example, homopolymers and copolymers of vinyl alcohol, acrylamide, methylol acrylamide, methylol methacrylamide, acrylic acid, methacrylic acid, hydroxyethyl acrylate, hydroxyethyl methacrylate or maleic anhydride/vinylmethylether copolymers. The hydrophilicity of the (co)polymer or (co)polymer mixture used is preferably the same as or higher than the hydrophilicity of polyvinyl acetate hydrolyzed to at least an extent of 60 percent by weight, preferably 80 percent by weight.

The amount of crosslinking agent, in particular of tetraalkyl orthosilicate, is preferably at least 0.2 parts by weight per part by weight of hydrophilic binder, preferably between 0.5 and 5 parts by weight, more preferably between 1.0 parts by weight and 3 parts by weight.

An ink-repellant layer in a lithographic base used in accordance with the present embodiment preferably also contains substances that increase the mechanical strength and the porosity of the layer. For this purpose colloidal silica may be used. The colloidal silica employed may be in the form of any commercially available water-dispersion of colloidal silica for example having an average particle size up to 40 nm, e.g. 20 nm. In addition inert particles of larger size than the colloidal silica can be added e.g. silica prepared according to Stöber as described in J. Colloid and Interface Sci., Vol. 26, 1968, pages 62 to 69 or alumina particles or particles having an average diameter of at least 100 nm which are particles of titanium dioxide or other heavy metal oxides. By incorporating these particles the surface of the ink-repellant layer is given a uniform rough texture consisting of microscopic hills and valleys, which serve as storage places for water in background areas.

The thickness of an ink-repellant layer in a lithographic base in accordance with this embodiment may vary in the range of 0.2 to 25 µm and is preferably 1 to 10 µm.

Particular examples of suitable ink-repellant layers for use in accordance with the present invention are disclosed in EP-A 601240, GB-P-1419512, FR-P-2300354, US-P-3971660, US-P-4284705 and EP-A 514490.

As flexible support of a lithographic base in connection with the present embodiment it is particularly preferred to use a plastic film e.g. substrated polyethylene terephthalate film, polyethylene naphthalate film, cellulose acetate film, polystyrene film, polycarbonate film etc... The plastic film support may be opaque or transparent.

It is particularly preferred to use a polyester film support to which an adhesion improving layer has been provided. Particularly suitable adhesion improving layers for use in accordance with the present invention comprise a hydrophilic binder and colloidal silica as disclosed in EP-A 619524, EP-A 620502 and EP-A 619525. Preferably, the amount of silica in the adhesion improving layer is 200 mg per m² and 750 mg per m². Further, the ratio of silica to hydrophilic binder is preferably more than 1 and the surface area of the colloidal silica is preferably at least 300 m² per gram, more preferably a surface area of 500 m² per gram.

In accordance with the present invention, on top of a hydrophilic surface there is provided a photosensitive layer. Optionally, there may be provided one or more intermediate layers between the lithographic base and the photosensitive layer.

In addition to the aryldiazosulfonate resin, the photosensitive layer according to the present invention preferably contains dispersed water-insoluble polymers. The aqueous dispersion of water insoluble polymer is preferably cationic or nonionic either e.g. as a result of an emulsifier or by having the anionic or nonionic group linked to the polymer. The water insoluble polymer is preferably a solid particulate having a size in the range of about 100 Angstroms to 1 micron in diameter and does not form a film below 30 °C. In general, any polymer which carries an anionic or nonionic group or which can be formulated into an emulsion using an anionic or nonionic emulsifier can be employed in the present invention. Suitable polymers include homopolymers and copolymers of styrene, methylacrylate, ethylacrylate, butylacrylate, methylmethacrylate, ethylmethacrylate, butyl methacrylate, vinyl acetate, vinyl chloride, vinylidene chloride, butadiene, methyl styrene, vinyl toluene, dimethylaminoethyl acrylate, acrylic acid, methacrylic acid, isoprene, chloroprene, malei anhydride, ethylene glycol acrylates such as polyethylene glycol acrylate, halogenated vinyl aromatics such as chlorostyrene and bromostyrene, methylvinyl ether, vinyl pyrrolidone, polyurethane and the like.

The thickness of the photosensitive layer in the material of this invention may vary in the range of 0.1 to 10 µm and is preferably between 0.5 and 2.5 µm.

The photosensitivity of an imaging element in connection with the present invention is preferably such that an exposure to day light to an extent of not more than 250 000 lux.s does not substantially result in changes in the lithographic behaviour of the printing plate. This will allow sufficient convenience in handling and mounting of an image-wise exposed imaging element. The photosensitivity of the imaging element may be easily adapted by appropriate choice of

a particular aryldiazosulfonate resin, the amount thereof and the thickness of the photosensitive layer.

The imaging element in connection with the present invention advantageously contains water-soluble dyes such as rhodamines, phthalocyanines, sudan blue, methylen blue, eosin or triphenylmethane dyes such as crystal violet, victoria pure blue, malachite green, methylviolet and fuchsin or dye pigments. These colorants may be incorporated in the photosensitive layer and/or ink-repellant layer.

The exposure of the imaging element used in the present invention advantageously proceeds with ultraviolet light optionally in combination with blue light in the wavelength range of 250 to 500 nm. Useful exposure sources are high or medium pressure halogen mercury vapour lamps, e.g. of 1000 W. Since most lithography is done by the offset process, the imaging element is exposed in such a way that the image obtained thereon is right reading. The exposure may be an exposure using optics or a contact exposure.

Subsequent to image-wise exposure, the image-wise exposed imaging element, after optional wiping, is mounted on a print cylinder of a printing press with the backside of the imaging element (side of the support opposite to the side having the photosensitive layer). According to a preferred embodiment, the printing press is then started and while the print cylinder with the imaging element mounted thereon rotates, the dampener rollers that supply dampening liquid are dropped on the imaging element and subsequent thereto the ink rollers are dropped. Generally, after about 10 revolutions of the print cylinder the first clear and useful prints are obtained.

According to an alternative method, the ink rollers and dampener rollers may be dropped simultaneously or the ink rollers may be dropped first.

Preferably, the photosensitive layer of an image-wise exposed imaging element in accordance with the present invention is wiped with e.g. a cotton pad or sponge soaked with water before mounting the imaging element on the press or at least before the printing press starts running. This will remove some unexposed aryldiazosulfonate resin but will not actually develop the imaging element. However, it has the advantage that possible substantial contamination of the dampening system of the press and ink used is avoided.

An exposed imaging element in accordance with the present invention is preferably mounted on a printing press and used to print shortly after the exposure. It is however possible to store an exposed imaging element for some time in the dark before using it on a printing press to print copies.

Suitable dampening liquids that can be used in connection with the present invention are aqueous liquids generally having an acidic pH and comprising an alcohol such as isopropanol. With regard to dampening liquids useful in the present invention, there is no particular limitation and commercially available dampening liquids, also known as fountain solutions, can be used.

The invention will now be illustrated by the following examples without however the intention to limit the invention thereto. All parts are by weight unless stated otherwise.

EXAMPLE 1

Preparation of a lithographic base

A 0.2mm thick aluminium foil was degreased by immersing the foil in an aqueous solution containing 5g/l of sodium hydroxide at 50°C and rinsed with demineralised water. The foil was then electrochemically grained using an alternating current in an aqueous solution containing 4g/l of hydrochloric acid, 4 g/l of hydroboric acid and 0.5g/l of aluminium ions at a temperature of 35°C and a current density of 1200 A/m² to form a surface topography with an average center-line roughness R_a of 0.5µm.

After rinsing with demineralised water the aluminium foil was then etched with an aqueous solution containing 300g/l of sulfuric acid at 60°C for 180 seconds and rinsed with demineralised water at 25°C for 30 seconds.

The foil was subsequently subjected to anodic oxidation in an aqueous solution containing 200 g/l of sulfuric acid at a temperature of 45°C, a voltage of about 10V and a current density of 150 A/m² for about 300 seconds to form an anodic oxidation film of 3g/m² Al₂O₃, then washed with demineralised water, post treated with a solution containing 20 g/l of sodium bicarbonated at 40°C for 30s, subsequently rinsed with demineralised water of 20°C during 120s and dried.

The obtained lithographic base was submersed in an aqueous solution containing 5% by weight of citric acid for 60s, rinsed with demineralised water and dried at 40°C.

Preparation of the imaging element (material)

An imaging element according to the invention was produced by preparing the following coating composition and coating it to the above described lithographic base in an amount of 30g/m² (wet coating amount) and drying it at 35°C.

Preparation of coating composition

2 gram of a copolymer of 3-methacrylamido-phenylazosulfonate and methylmethacrylate (molar ratio 60/40), was dissolved in 66ml of demineralised water and wetting agent was added thereto.

Preparation of a printing plate and printed copies therefrom.

An imaging element as described above was exposed through an original (mask) to a high pressure halogen mercury vapour lamp in a DL2000™ (commercially available from Agfa-Gevaert NV) contact frame exposure apparatus. The exposed imaging element was then mounted on an ABD360™ offset printing press equipped with a VARN™ KOM-PAC II dampening system. As ink, VanSon RB2329™ and as dampening liquid G671c™ (3% in water) commercially available from Agfa-Gevaert NV were used.

Subsequently, the press was started by allowing the print cylinder with the imaging element mounted thereon to rotate. The dampener rollers of the press were then dropped on the imaging element so as to supply dampening liquid to the imaging element and after 10 revolutions of the print cylinder, the ink rollers were also dropped to supply ink. After 10 further revolutions clear prints were obtained with no ink uptake in the non-image parts.

EXAMPLE 2

An imaging element was prepared as described in example 1 with the exception that the submersion of the lithographic base in a citric acid solution was omitted and the lithographic base was directly coated with the coating composition.

A printing plate was prepared as in example 1 and after a total of 20 revolutions of the print cylinder, clear prints were obtained without ink uptake in the non-image areas.

EXAMPLE 3

Preparation of a lithographic base

To 440 g of a dispersion contg. 21.5% TiO₂ (average particle size 0.3 to 0.5 µm) and 2.5% polyvinyl alcohol in deionized water were subsequently added, while stirring, 250 g of a 5% polyvinyl alcohol solution in water, 105 g of a hydrolyzed 22% tetramethylorthosilicate emulsion in water and 12 g of a 10% solution of a wetting agent.

To this mixture was added 193 g of deionized water and the pH was adjusted to pH=4.

The obtained dispersion was coated on a polyethyleneterephthalate film support (coated with a hydrophilic adhesion layer) to a wet coating thickness of 50 g/m², dried at 30 °C. and subsequently hardened by subjecting it to a temperature of 57 °C for 1 week.

An imaging element was prepared as described in example 1 with the exception that the above lithographic base was used instead of the lithographic base described in example 1.

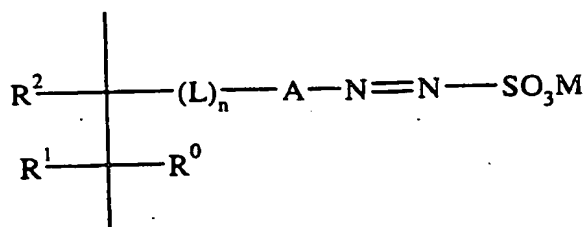
A printing plate and printed copies therefrom were prepared as described in example 1 and after a total of 20 revolutions of the print cylinder, clear prints were obtained without ink uptake in the non-image areas.

Claims

1. A method for making a lithographic printing plate comprising the steps of:

- (1) image-wise exposing an imaging element having on a hydrophilic surface of a lithographic base a photosensitive layer comprising a photosensitive polymer containing aryl-diazosulfonate units;
- (2) and developing a thus obtained image-wise exposed imaging element by mounting it on a print cylinder of a printing press and supplying an aqueous dampening liquid and/or ink to said photosensitive layer while rotating said print cylinder.

2. A method according to claim 1 wherein said polymer contains aryl-diazosulfonate units according to the following general formula:



wherein R^{0,1,2} each independently represent hydrogen, an alkyl group, a nitrile or a halogen, L represents a divalent linking group, n represents 0 or 1, A represents an aryl group and M represents a cation.

3. A method according to claim 1 wherein L represents a divalent linking group selected from the group consisting of:
- $(X)_1$ -CONR³-, - $(X)_1$ -COO-, -X- and - $(X)_1$ -CO-, wherein t represents 0 or 1, R³ represents hydrogen, an alkyl group or an aryl group, X represents an alkylene group, an arylene group, an alkyleneoxy group, an aryleneoxy group, an alkyleneethio group, an aryleneethio group, an alkyleneamino group, an aryleneamino group, oxygen, sulfur or an aminogroup.
4. A method according to claim 2 or 3 wherein A represents an unsubstituted aryl group or an aryl group substituted with one or more alkyl group, aryl group, alkoxy group, aryloxy group or amino group.
5. A method according to claim 2 wherein M represents NH₄⁺ or a metal ion.
6. A method according to any of the above claims wherein said lithographic base is an anodised aluminium or comprises a support coated with an ink-repellant layer containing a cross-linked hydrophilic binder.
7. A method for making multiple copies of an original comprising the steps of:
 - (1) image-wise exposing an imaging element having on a hydrophilic surface of a lithographic base a photosensitive layer comprising a photosensitive polymer containing aryl-diazosulfonate units;
 - (2) mounting a thus obtained image-wise exposed imaging element without development, on a print cylinder of a printing press;
 - (3) rotating said print cylinder while supplying an aqueous dampening liquid and/or supplying ink to said photosensitive layer of said imaging element and
 - (4) transferring ink from said imaging element to a receiving element.
8. A method according to claim 7 wherein said image-wise exposed imaging element is wiped before rotating said print cylinder while supplying dampening liquid and/or ink.



European Patent
Office

EUROPEAN SEARCH REPORT

Application Number
EP 95 20 2936

DOCUMENTS CONSIDERED TO BE RELEVANT				
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int.Cl.6)	
X	WO-A-93 05446 (POLAROID CORP) 18 March 1993	1-9	B41C1/10 G03F7/016	
Y	* the whole document *	1		
Y	US-A-4 034 183 (UHLIG FRITZ) 5 July 1977 * the whole document *	1		
Y	EP-A-0 601 240 (AGFA-GEVAERT N.V.) * the whole document *	1		
Y,D	EP-A-0 507 008 (AGFA GEVAERT NV) 7 October 1992 * the whole document *	1		
Y	WO-A-90 02044 (PRESSTEK INC) * page 24, line 7 - line 15 *	1		
A	WO-A-95 12836 (POLAROID CORP) 11 May 1995 * the whole document *	1		
E	EP-A-0 703 499 (MINNESOTA MINING & MFG) 27 March 1996 * the whole document *	1		TECHNICAL FIELDS SEARCHED (Int.Cl.6)
A	DE-A-34 38 882 (HEIDELBERGER DRUCKMASCH AG) 24 April 1986 * the whole document *	1		G03F B41C
A	FR-A-2 683 766 (HEIDELBERGER) 21 May 1993 * the whole document *	1		
Y,D	EP-A-0 339 393 (BAYER AG) 2 November 1989 * the whole document *	1		
The present search report has been drawn up for all claims				
Place of search THE HAGUE		Date of completion of the search 14 June 1996	Examiner Rasschaert, A	
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document				

EPO FORM 1503 01.92 (PM/C01)